The Particular Sensitivity of Silvl Ethers of D-Glucal toward Two Vilsmeier-Haack Reagents $POCl_3 \cdot DMF$ and $(CF_3SO_2)_2O \cdot DMF$. Their Unique and Selective Conversion to the Corresponding C(6)-O-Formates

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The two electrophilic Vilsmeier—Haack reagents POCl₃·DMF 2 or (CF₃SO₂)₂O·DMF 3 mediate the one-step and selective conversion of O-triethylsilyl (O-TES), O-tert-butyldimethylsilyl (O-TBDMS), O-tert-butyldiphenylsilyl (O-TBDPS), and O-triisopropylsilyl (O-TIPS) ethers of p-glucal to the corresponding C(6)-O-formates.

Introduction

Silvl ethers RO-SiR'₃ 1 have become the most popular protecting groups for hydroxyl functions during complex multistep syntheses, especially when orthogonal protective/deprotective steps are required.^{1,2} These ethers display a unique set of properties, ranging from their easy introduction, through their good stability over a wide range of conditions, to the variety of their one-step deprotections by well-known fluoride-based, basic/acidic or strongly oxidizing/reducing reagents. 1,2 Nevertheless, if performed on multifunctional or sensitive molecules, one-step *O*-silyl ether deprotections may be problematic, requiring milder conditions.^{3,4} Alternatively, innovative two-step procedures interconverting 1 to a different kind of protected ether RO-Pg (Pg: protecting group) followed by smooth hydrolysis of the Pg (RO−SiR'₃ → RO−Pg → ROH) could be also of interest, each approach possessing its particular advantages and limitations.

On the basis of these considerations, we very recently performed some preliminary experiments on the neutral one-step transformation of O-TBDMS/O-TES ethers of type 1 (R alkyl residue, Scheme 1) to their corresponding formates RO–CHO 7, promoted by the Vilsmeier–Haack reagent POCl $_3$ -DMF 2 5,6 (equilibrium mixture of the two salts 8 and 9, Figure 1 and Scheme 1: anhydrous DMF, 0 °C to 20 °C, yield range: 62-98%). 7 A likely mechanism is addition of the Vilsmeier-Haack reagent 2 to the silyl ether 1 to afford the intermediate oxonium cations 4a

(mixture of Cl⁻ and/or Cl₂P(O)O⁻ counteranions). Due to the formation of the thermodynamically strong Si-Cl/ Si-O bonds (111.0 and 128.2 kcal, respectively),8 the elimination of the neutral species R'_3Si-X_1 5a $(R'_3Si =$ TES or TBDMS, $X_1 = Cl \text{ and/or } O(O)PCl_2)$ generates in situ the related imidate salts 6a (mixture of same counteranions), whose subsequent smooth hydrolysis affords the corresponding formate 7. To the best of our knowledge, only very few OH-protecting group exchange reactions are known, none affording formates from silyl ethers, as described above. 9a-h Consequently, considering the easy and high-yielding deprotection of formates,1 such an OH-protecting group interconversion R-OTBDMS/R-OTES → R-OCHO could constitute the first step of an innovative two-step deprotection variant of 1, provided that it could be generalized to other kinds of O-silyl ethers and, preferably, multifunctional ones.

The purpose of this communication is to report our recent results generalizing this one-step conversion promoted by the Vilsmeier-Haack reagent 2 (RO-SiR'3 $1 \rightarrow RO-CHO$ 7, various R and R', Schemes 1-3 and Table 1). The second more electrophilic Vilsmeier-Haack complex (CF₃SO₂)₂O·DMF 3 (Figure 1), known to be superior in the formylation of electronically deficient

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Scheme 1. One-Step Conversion of O-Silyl Ethers 1 to the Corresponding Formates 7

$$\begin{array}{c} \text{POCl}_3 \cdot \text{DMF 2 or} \\ (\text{CF}_3 \text{SO}_2)_2 \text{O} \cdot \text{DMF 3} \\ \hline \\ \text{(various SiR'_3 and conditions, see text)} \end{array} \begin{array}{c} X_1 \\ X_2 \\ X_2 \\ X_2 \\ \hline \\ \text{NMe}_2 \end{array} \begin{array}{c} - R'_3 \text{SiX}_1 \\ \hline \\ \text{Sa/5b: } X_1 = -\text{Cl} \\ \text{or -O(O)PCl}_2 \text{/-OTf} \\ \text{or } Cl_2 \text{P(O)O-, Cl} \\ \textbf{4b: } X_1 = X_2 = \text{OTf} \end{array} \begin{array}{c} \text{Me}_{\text{N}} \cdot \text{Me}_{\text{N}} \\ \text{Me}_{\text{N}} \cdot \text{Me}_{\text{N}} \\ \text{RO} \end{array} \begin{array}{c} \text{Hydrolysis} \\ \text{RO-CHO} \\ \text{RO} \end{array}$$

$$\begin{bmatrix} & & & & & \\ & & & \\ &$$

Figure 1. Vilsmeier-Haack complexes **2** and **3**.

aromatics, 10 was also capable of promoting this transformation, but with reactivity trends slightly different from those of 2, depending on the substrates and conditions. In this study, the densely functionalized *O*-silylated D-glucal-based precursors 12-15, 20-23, and 25 were used as model compounds to explore the scope and some of the limitations of this transformation (Schemes 1-3). The main premises that guided our substrate design were that (1) these sugar cyclic enol ethers are mostly acid-sensitive, (2) these enol ethers contain, on the same unsaturated cyclic carbon skeleton, a dense array of *O*-silyl ethers of primary, secondary/secondary allylic nature in 1.2-/ 1,3-/1,4-relationships, and therefore provide different reactivities, and (3) the particular substrates 12-15 and **20–23** can be used to test the *C*-formylation of their intracyclic enol ether functions to afford C(2)-CHO compounds of type 24 which, potentially, should compete with the expected O-formylation (Scheme 2).11

Results and Discussion

Preparation of the *O*-Silylated Substrates 12-15, **20–23, and 25.** The preparation of the required *O*silylated D-glucal-based precursors 12-15, 20-23, and 25 began from D-glucal 10, obtained by basic methanolysis of tri-O-acetyl-D-glucal (catalytic MeONa, MeOH, 0-20 °C, quantitative yield) or from the known tri-Obenzyl-D-glucal 11¹² (Scheme 2). The carbohydrate 10 could be either persilylated or selectively silylated at its primary C(6)-OH with different chlorosilanes having various degrees of steric hindrance, such as TES-Cl, TBDMS-Cl, TBDPS-Cl, and TIPS-Cl (classical Hanessian's silylation protocol: chlorosilane: 1.0 or 3.3 equiv, depending on substrates, imidazole, anhydrous DMF, 20 $^{\circ}$ C or -18 $^{\circ}$ C, 14 h). 13 The fully and partially *O*-silylated compounds 12-15 and 16-19, respectively, were obtained in a 44-99% yield range. The C(6)-O-silylated

precursors **16–19** could be further benzylated to the O-silylated-3,4-di-O-benzyl-substrates **20–23** (NaH, anhydrous THF, BnBr, catalytic *n*Bu₄NI, 0−20 °C, 24 h, 37–86% nonoptimized yields). The presence of a catalytic amount of nBu₄NI in the medium (10% molar) was an absolute requirement for supressing base-mediated interor intramolecular silyl group migrations to give the observed regioselective C(3)-OH/C(4)-OH-benzylation.¹⁴ Furthermore, the C(2) regioselective Vilsmeier-Haack formylation of tri-O-benzyl-D-glucal 11 by reagents 2 or 3, followed by the chemoselective reduction of the resulting enal 24 (anhydrous DMF, 0-20 °C, overnight, 2: 60%, **3**: 70%; NaBH₄, MeOH, 20 °C, 20 min, 85%), afforded the 2-hydroxymethyl-3,4,6-tri-O-benzyl-D-glucal, 11,15 as the appropriate precursor of the allylic O-TBDMS ether **25** (same silvlation protocol as that given above using TBDMS-Cl, 90%, 46-54% overall yield from 11). Worthy of mention is the fact that, for the first time, reagent 3 was shown to formylate the sugar cyclic enol ether 11 with the same regioselectivity as 2, but in a better yield (2 and 3: 60% and 70%).

Reaction of the Vilsmeier-Haack Reagents POCl₃· DMF 2 and (CF₃SO₂)₂O·DMF 3 with O-Silylated Substrates 12-15, 20-23, and 25. Having multifunctional tri- and mono-O-silylated substrates 12-15, 20-23, and 25 at our disposal, we compared their reactivities toward the Vilsmeier-Haack reagents POCl₃·DMF 2 or (CF₃SO₂)₂O·DMF **3** with the aim of revealing the synthetic generality and the limits of this one-step OHprotecting group interconversion (Scheme 3 and Table 1; see the Supplementary Information for detailed general experimental procedures). The electrophilic reagents 2 and 3 are classically prepared in situ by slow addition of POCl₃ or (CF₃SO₂)₂O in anhydrous DMF under nitrogen at 0 °C and agitation over 30 min at same temperature. For all the *O*-silylated substrates under consideration, reagents 2 and 3 were used in a slight excess (10% molar) per *O*-silylated function (12-15: 1.0 mmol, 2/3: 3.3 equiv, 5.0 mL of DMF; **20–23** and **25**: 1.0 mmol, 2/3: 1.1 equiv, 3.0 mL of DMF).

From the results given in Table 1, several valuable conclusions may be drawn:

1. Irrespective of the silylation pattern of silyl groups present in the substrates $\bf 13-15$ and $\bf 20-23$, the expected O-formylation was promoted by reagents $\bf 2$ and $\bf 3$, affording the corresponding formates $\bf 27-30$ in a medium- to high-yield range (entries $\bf 3-5$ and $\bf 7-10$, $\bf 50-91\%$). More particularly, reagent $\bf 3$ was more reactive than $\bf 2$ to formylate the tri-O-TBDMS substrate $\bf 13$ (entry $\bf 3$: $\bf 8$ h versus $\bf 6$ h) for similar yields in $\bf 27$ ($\bf 70-69\%$). Slightly improving the yield, the same reactivity trend was observed for the addition of anhydrous pyridine (3.3 equiv/ $\bf 13$, entries $\bf 3$ versus $\bf 4$: $\bf 8$ h- $\bf 70\%$ /72 h- $\bf 80\%$ and $\bf 6$

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Scheme 2.^a Preparation of O-Silylated D-Glucal-Based Substrates 12-15, 20-23, and 25

^a Key: (a) chlorosilane (1.0 or 3.3 equiv/10, see text and Supporting Information), imidazole, anhydrous DMF, 20 °C (12-15) or -18 °C (16–19), 14 h; (b) NaH, anhydrous THF, cat. nBu₄NI, BnBr, 0 °C to 20 °C, 24 h; (c) POCl₃·DMF 2 or (CF₃SO₂)₂O·DMF 3, anhydrous DMF, 0 °C to 20 °C, overnight; (d) NaBH₄, EtOH, 20 °C, 20 min; (e) TBDMS-Cl, imidazole, anhydrous DMF, 20 °C, 14 h.

Scheme 3^a 26 OCHO (see Table) 27: $R_6 = TBDMS$ **13**: $R_4 = R_5 = TBDMS$ **14**: $R_4 = R_5 = TBDPS$ 28: R₆ = TBDPS 29: R₆ = TIPS 15: R4 = R5 = TIPS **20**: $R_4 = Bn, R_5 = TES$ 21: $R_4 = Bn$, $R_5 = TBDMS$ **30**: $R_6 = Bn$ **22**: R_4 = Bn, R_5 = TBDPS **23**: $R_4 = Bn, R_5 = TIPS$

^a Key: (f) POCl₃·DMF 2 or (CF₃SO₂)₂O·DMF 3, anhydrous DMF, 0 °C to 20 °C.

h-69%/48 h-78%). Moreover, the tri-*O*-TBDPS-precursor 14 was more efficiently converted to the corresponding formate 28 by the more electrophilic 3 (entry 5: 50% and 65%). Analogous conclusions about the comparative reactivity and synthetic efficiency of 3 versus 2 may be drawn for the second series of O(6)-silylated-3,4-di-Obenzyl-substrates **20–23** (entries 7–10). Yields of the *O*-(6)-formate 30 were systematically higher with 3 than with 2, while, in parallel, reaction times to completion were reduced. Interestingly, the silyl groups in 20-23 can be graded by their decreasing O(6)-formylation reactivity toward 2 and 3, as follows, 2: TES \gg TBDMS \gg TIPS \gg TBDPS and **3**: TES \gg TBDMS \gg TBDPS \sim TIPS. This reactivity scale roughly follows increasing steric hindrance at silicon.

Table 1. Reaction of Vilsmeier-Haack Reagents 2 and 3 with O-Silylated D-Glucal Derivatives 12-15, 20-23, and 25

entry	precursor	product (R ₆₎	reagent 2 $[(\%)^a, (h)^b]$		reagent 3 [(%) a , (h) b]	
1	12	_	-	0.5	_	0.5
2	12	_	-	0.5^d	_	0.5^d
3	13	27 (TBDMS)	70	8	69	6
4	13	27 (TBDMS)	80^d	72	78^d	48
5	14	28 (TBDPS)	50	8	65	8
6	15	29 (TIPS)	5 - 10	48	5 - 10	48
7	20	30 (Bn)	70	3	84	2
8	21	30 (Bn)	82	4.5	85	3.5
9	22	30 (Bn)	60	24	70	8
10	23	30 (Bn)	85	8	91	8
11	25	_	_	$0.5^{c,d}$	_	$0.5^{c,d}$
12	27	no reaction	_	4.5	_	4.5
13	30	no reaction	_	24	_	24

^a Yields of isolated purified compounds. ^b Reaction time for substrate consumption (TLC check). ^c The starting glucal derivative is consumed without formation of any formate. ^d Anhydrous pyridine (1.1 equiv. per O-silyl function) is added to Vilsmeier-Haack complex prior to the glucal derivative.

Interestingly, the dense and varied protection pattern of C(3)/C(4)-hydroxyl groups in substrates 15 and 23 (O-Bn versus O-TIPS groups) drastically modified the course of formylation. Indeed, the TIPS OH-protecting group in 15 can be considered stable toward 2 and 3, since less than 5-10% conversion to the corresponding C(6)-Oformate **29** was observed in 48 h (entry 6). In contrast, the sterically less encumbered 6-O-triisopropylsilyl-3,4di-O-benzyl-D-glucal 23 afforded the expected C(6)-Oformate 30 in very good yields (entry 10, 2 and 3: 8 h, 85% and 91%).

Relative to substrates **13–14** and **20–23**, the presence of the strong Lewis acids R'₃Si-OTf in the medium compared to that of the neutral species R'_3Si-X_1 ($X_1 =$ Cl/O(O)PCl₂), respectively generated from reagents 3 and 2, does not seem particularly detrimental to the conversion.

2. Some limitations for this conversion have been encountered. For example, the tri-O-TES-D-glucal 12 was destroyed in less than 30 min when reacted with 2 or 3 (TLC check, entry 1). Similarly, since involving the highly stabilized carbocation 26 (Scheme 3), the same result was obtained with the extremely acid-sensitive substrate **25** (entry 11). Even the reaction in the presence of anhydrous pyridine (3.3 equiv/**12** and 1.1 equiv/**25**) to quench adventitious acids followed the same trend (entries 2 and 11).

3. Particularly striking in the case of the tri-O-silylated substrates **13**–**15**, was the exquisite regioselectivity of O-formylation, affording the C(6)-O-formates **27**–**29**, since only the primary C(6)-O-silylated function was formylated versus the other allylic functions (entries 3–5, 50–80% yield). This selectivity feature was found for both Vilsmeier–Haack reagents in a similar yield range (2: 50–80%, **3**: 65–78%). FT-IR and 1 H/ 13 C NMR data were in good agreement with the depicted structures ($\nu_{O-C=O}$: 1716–1792 cm $^{-1}$, δ_{CHO} and δ_{CHO} (500 and 50 MHz, CDCl₃): 7.98–8.09 ppm, singlet and 160.5–160.8 ppm). In addition, the H_{6,6'} protons in **27–29** were strongly deshielded by the C(6)-formate group, in comparison with the respective substrates **13–15** (see the relevant spectroscopic data in the Supporting Information).

4. The observed selectivity supports the involvement of a common intermediate salt of type **6a/6b**, that contains a positively charged imidate function formed solely at the C(6)-primary position because of steric reasons (Scheme 1). Even in the presence of a 2-fold excess of **2** or **3**, this imidate function critically positioned at C(6) electronically "disarms" the D-glucal-based intermediates **6a/6b** toward further electrophilic attack of any additional Si-O bonds. ^{16,17} The same reasoning explains why glucal-based unsaturated aldehydes of type **24** arising from the C(2)-formylation of substrates **13**–**15** and **20**–**23** by **2** and **3** could not be isolated, as depicted

previously for structurally similar compounds (entries 3-5 and 7-10). Worthy of mention also is the lack of additional *O*- or C(2)-formylation of the C(6)-*O*-formylated-substrates **27** and **30** possessing an electron-withdrawing formyl group at the same critical C(6) primary position (entries 12 and 13).

In conclusion, we demonstrated that O-TES, O-TBDMS, O-TBDPS, and O-TIPS silyl ethers of D-glucal are quite sensitive to the two electrophilic Vilsmeier— Haack reagents $POCl_3 \cdot DMF$ **2** or $(CF_3SO_2)_2O \cdot DMF$ **3** being converted *in one step and selectively* to the corresponding C(6)-O-formates. The reactivity trends of these two reagents as well as the scope and some limitations of this OH-protecting group interconversion were examined. Additionally, since formates of (–)-menthol and 3β -cholesterol have been deprotected in mild conditions known to be compatible with O-silyl ethers (0.6 M NH₄OH in MeOH, 20 °C), ^{1,7} this transformation will allow the straight preparation of differentially protected D-glucal derivatives.

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Supporting Information Available: Detailed experimental procedures (including references for each known compounds) for the preparation of *O*-silylated precursors **12–15**, **20–23**, and **25** and corresponding formates **27–30** (added with relevant spectroscopic characterization, ¹H- and ¹³C NMR spectra). This material is available free of charge via the Internet at http://pubs.acs.org.

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